Guojin Chen

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Current Position

Visiting Student, The University of Texas at Austin 2023.08 – Present

Supervisor: Prof. David Z. Pan

Ph.D. Candidate, The Chinese University of Hong Kong 2021.08 – Present

Supervisor : Prof. Bei Yu

Education

Ph.D. in Computer Science, The Chinese University of Hong Kong	2021 – Present
M.S. in Computer Science, The Chinese University of Hong Kong	2019 - 2020
B.S. in Computer Science, Huazhong University of Science and Technology	2015 - 2019

Research Interests

- Design for manufacturing (DFM) / Electronic design automation (EDA)
- Computational lithography / Resolution enhancement technologies
- Deep Learning for VLSI / Physics-informed deep learning

Publications [Google Scholar; 103+ citations, h-index: 5+]

Representative publications that I am a primary author on are highlighted.

Conference papers.....

- [C12] Open-Source Differentiable Lithography Imaging Framework Guojin Chen, Hao Geng, Bei Yu, and David Z. Pan (SPIE 2024) DTCO and Computational Patterning II
- [C11] AlphaSyn: Logic Synthesis Optimization with Efficient Monte Carlo Tree Search Zehua Pei, Fangzhou Liu, Zhuolun He, Guojin Chen, Haisheng Zheng, Keren Zhu, and Bei Yu (ICCAD 2023) Proceedings of the 42th International Conference on Computer-Aided Design
- [C10] Physics-Informed Optical Kernel Regression Using Complex-valued Neural Fields

 Guojin Chen, Zehua Pei, Haoyu Yang, Yuzhe Ma, Bei Yu, and Martin Wong

 (DAC 2023) ACM/IEEE Design Automation Conference (Best score in DFM track.)
- [C9] DiffPattern: Layout Pattern Generation via Discrete Diffusion Zixiao Wang, Yunheng Shen, Wenqian Zhao, Yang Bai, Guojin Chen, Farzan Farnia, and Bei Yu (DAC 2023) ACM/IEEE Design Automation Conference
- [C8] GPU-accelerated Matrix Cover Algorithm for Multiple Patterning Layout Decomposition Guojin Chen, Haoyu Yang, and Bei Yu (SPIE 2023) DTCO and Computational Patterning II
- [C7] Efficient Point Cloud Analysis Using Hilbert Curve.
 Wanli Chen, Xinge Zhu, Guojin Chen, and Bei Yu
 (ECCV 2022) European Conference on Computer Vision
- [C6] AdaOPC: A Self-Adaptive Mask Optimization Framework For Real Design Patterns Wenqian Zhao, Xufeng Yao, Ziyang Yu, **Guojin Chen**, Yuzhe Ma, Bei Yu, and Martin Wong (**ICCAD 2022**) *Proceedings of the 41th International Conference on Computer-Aided Design*
- [C5] LayouTransformer: Generating Layout Patterns with Transformer via Sequential Pattern Modeling Liangjian Wen, Yi Zhu, Lei Ye, **Guojin Chen**, Bei Yu, Jianzhuang Liu, and Chunjing Xu (ICCAD 2022) Proceedings of the 41th International Conference on Computer-Aided Design

- [C4] DevelSet: Deep Neural Level Set for Instant Mask optimization Guojin Chen, Ziyang Yu, Hongduo Liu, Yuzhe Ma, and Bei Yu (ICCAD 2021) Proceedings of the 40th International Conference on Computer-Aided Design [C3] Learning Point Clouds in EDA. Wei Li, Guojin Chen, Haoyu Yang, Ran Chen, and Bei Yu
- [C2] DAMO: Deep Agile Mask Optimization for Full Chip Scale Guojin Chen, Wanli Chen, Yuzhe Ma, Haoyu Yang, and Bei Yu (ICCAD 2020) Proceedings of the 39th International Conference on Computer-Aided Design
- [C1] A GPU-enabled Level Set Method for Mask Optimization Ziyang Yu, Guojin Chen, Yuzhe Ma, and Bei Yu (DATE 2020) IEEE/ACM Proceedings Design, Automation and Test in Europe

(ISPD 2021) ACM International Symposium on Physical Design

Journal papers.....

- [J5] Ultra-Fast Source Mask Optimization via Conditional Discrete Diffusion Guojin Chen, Zixiao Wang, Bei Yu, David Z. Pan, and Martin D.F. Wong (TCAD 2024) IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems
- [J4] L2O-ILT: Learning to Optimize Inverse Lithography Techniques Binwu Zhu, Su Zheng, Ziyang Yu, Guojin Chen, Yuzhe Ma, Fan Yang, Bei Yu, and Martin Wong (TCAD 2023) IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems
- [J3] A GPU-Enabled Level-Set Method for Mask Optimization Ziyang Yu, Guojin Chen, Yuzhe Ma, and Bei Yu (TCAD 2023) IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems
- [J2] DevelSet: Deep Neural Level Set for Instant Mask optimization Guojin Chen, Ziyang Yu, Hongduo Liu, Yuzhe Ma, and Bei Yu (TCAD 2023) IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems
- [J1] DAMO: Deep Agile Mask Optimization for Full-Chip Scale Guojin Chen, Wanli Chen, Qi Sun, Yuzhe Ma, Haoyu Yang, and Bei Yu (TCAD 2022) IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems

Open Source Repositories

1. OpenOPC/OpenILT — ★66 — Open-source inverse lithography technology (ILT) framework	2023
2. ai4eda/awesome-Al4EDA — \star 78 — A curated paper list of existing AI for EDA studies.	2023

Experiences

Research Assistant, The Chinese University of Hong Kong	2020 - 2021
Research Intern, Tencent	2018 – 2019

Awards	
Ph.D. Studentship	2021 – 2025
By Chinese University of Hong Kong, 2021-2025 Outstanding Graduate	2019
By Huazhong University of Science and Technology	

Ongoing Projects

Differentiable Computational Lithography. Revamping lithography with a GPU-accelerated, differentiable workflow based on Abbe imaging, using automatic differentiation to target diverse resolution enhancement objectives.

Professional Activities

Paper Review / External Review.	
Design Automation Conference (DAC)	2021-2023
AAAI Conference on Artificial Intelligence (AAAI)	2022-2023
IEEE Transactions on Computer-Aided Design of Integrated Circuits and Systems (TCAD)	2022-2023